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## Stress relaxation in thin films due to grain boundary diffusion and dislocation glide

Ayas, Can

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# **Stress Relaxation in Thin Films due to Grain Boundary Diffusion & Dislocation Glide**

Can Ayas

**Stress Relaxation in Thin Films due to  
Grain Boundary Diffusion & Dislocation Glide**

Can Ayas

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To my beloved parents  
Bilge & Güvenç



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